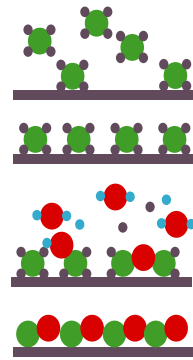


Atomic Layer Deposition:

Uses gas pulses to deposit thin film metals, semi-conductors, and insulators with atomic layer precision for micro-chemical systems, optics, and micro- and nano-electronics.

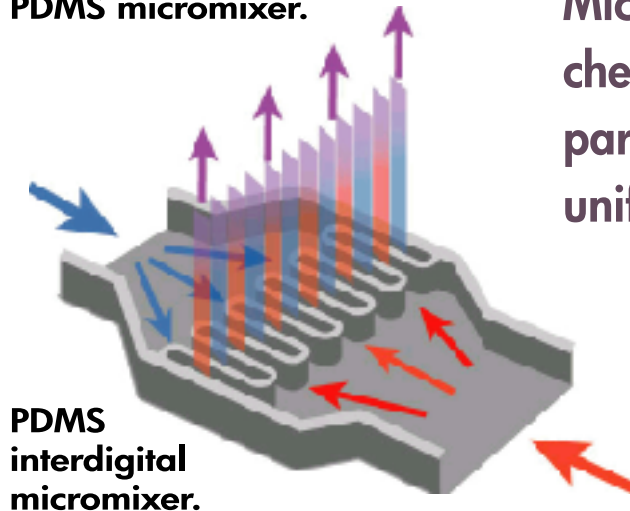


ALD process & reactor.

μ Techniques for η & μ Products



Optical image of the PDMS micromixer.



PDMS interdigital micromixer.

Micromixers:

Micro-mixing allows highly controlled chemical reactions that produce nano-particles of more uniform size.

Nano-particle solution of platinum & gold.

